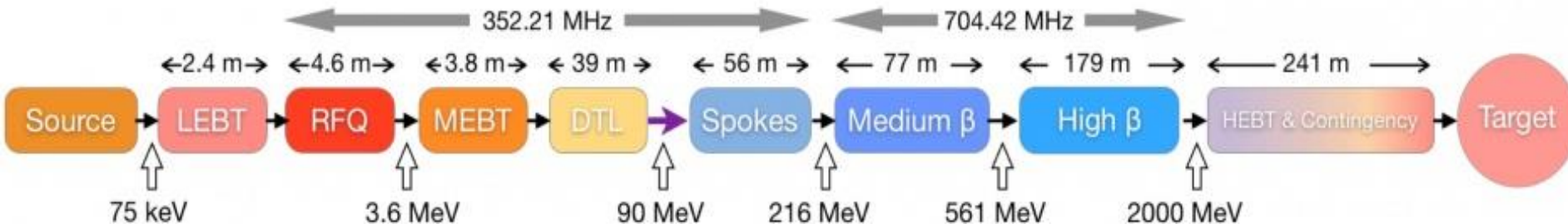


DE LA RECHERCHE À L'INDUSTRIE



# TEST BENCH CONDITIONING OF THE ESS COUPLERS FOR ELLIPTICAL CAVITIES

Optimus+



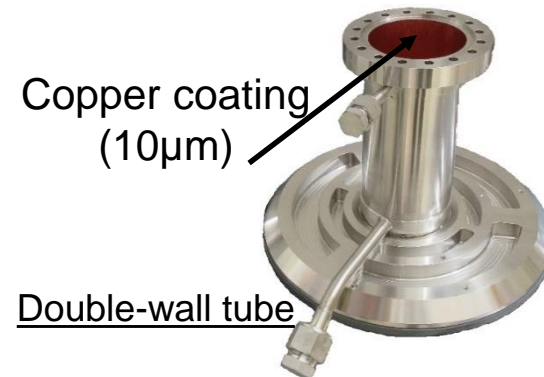
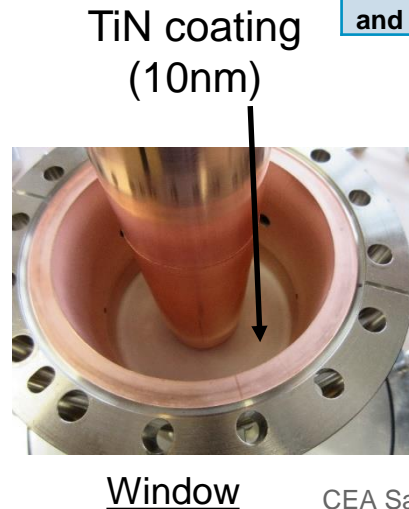
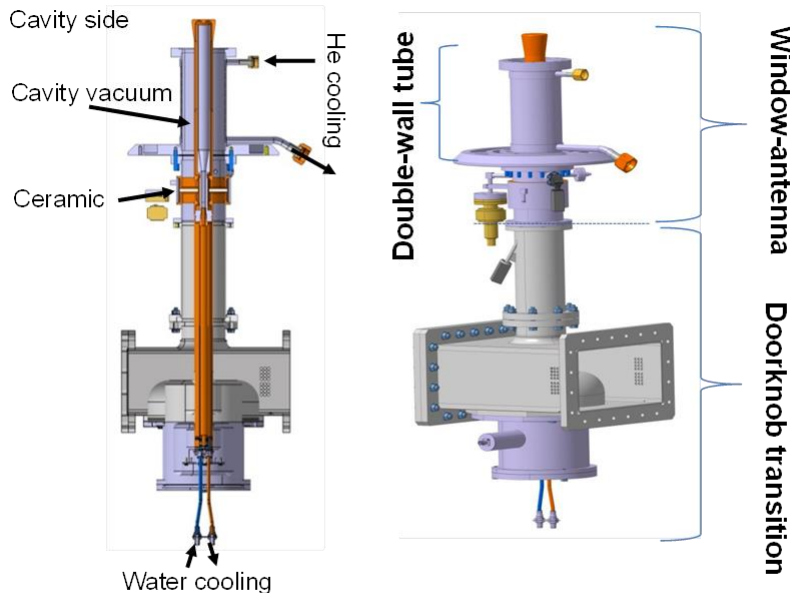
TTC MEETING –Christian ARCAMBAL

4TH FEBRUARY 2020

- **120** ESS couplers for elliptical cavities (36 medium beta (MB) whose 6 pre-series couplers + 84 high beta (HB) couplers).
- Three main parts: a **single window** with its antenna, a **double-wall tube**, a **doorknob transition**.
- Window-antenna and doorknob transitions common to MB and HB cavities. Double-wall tube slightly different between the 2 kinds of cavities: only the tube length is modified
- Cooling circuits:
  - Inner conductor: **water cooling**
  - Ceramic of the window: **natural air convection**
  - Double-wall tube: **Helium cooling**
- **Copper coating and TiN coating.**

Technical specifications

RF frequency	704.42MHz
Repetition frequency	14 Hz
Incident RF power	1.1 MW (peak)
RF pulse width in full reflection (all phases)	500 $\mu$ s
RF pulse width in travelling waves	3.6 ms
Voltage withstand (voltage between internal conductor and external conductor)	$\pm 10$ kV

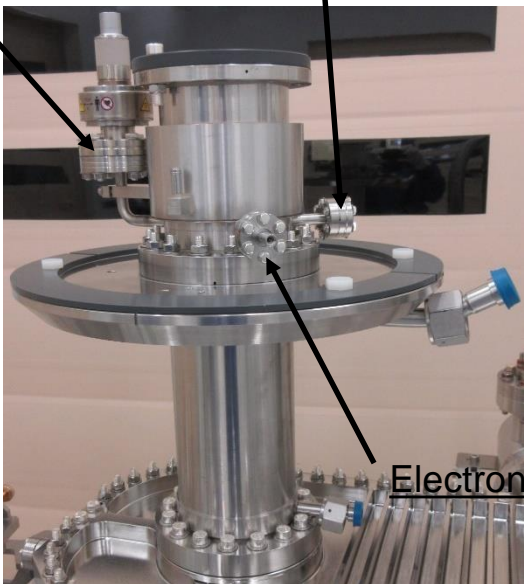


- Control instruments on the ESS couplers:
  - Vacuum gauge (IKR070 from Pfeiffer)
  - Window for photomultiplier (model H10721-110 from HAMAMATSU) (ceramic on the vacuum side)
  - Photomultiplier on the doorknob transition (ceramic on the air side)
  - Electron pick-up (for multipactor + RF coupling)
- Control instruments on the coupling box and pumping system:
  - Window for photomultiplier on the coupling box
  - Vacuum gauges on the pumping system



Electron pick-up

Vacuum gauge      Window for photomultiplier



Electron pick-up

Photomultiplier (vacuum side)



Position of the ceramic disk

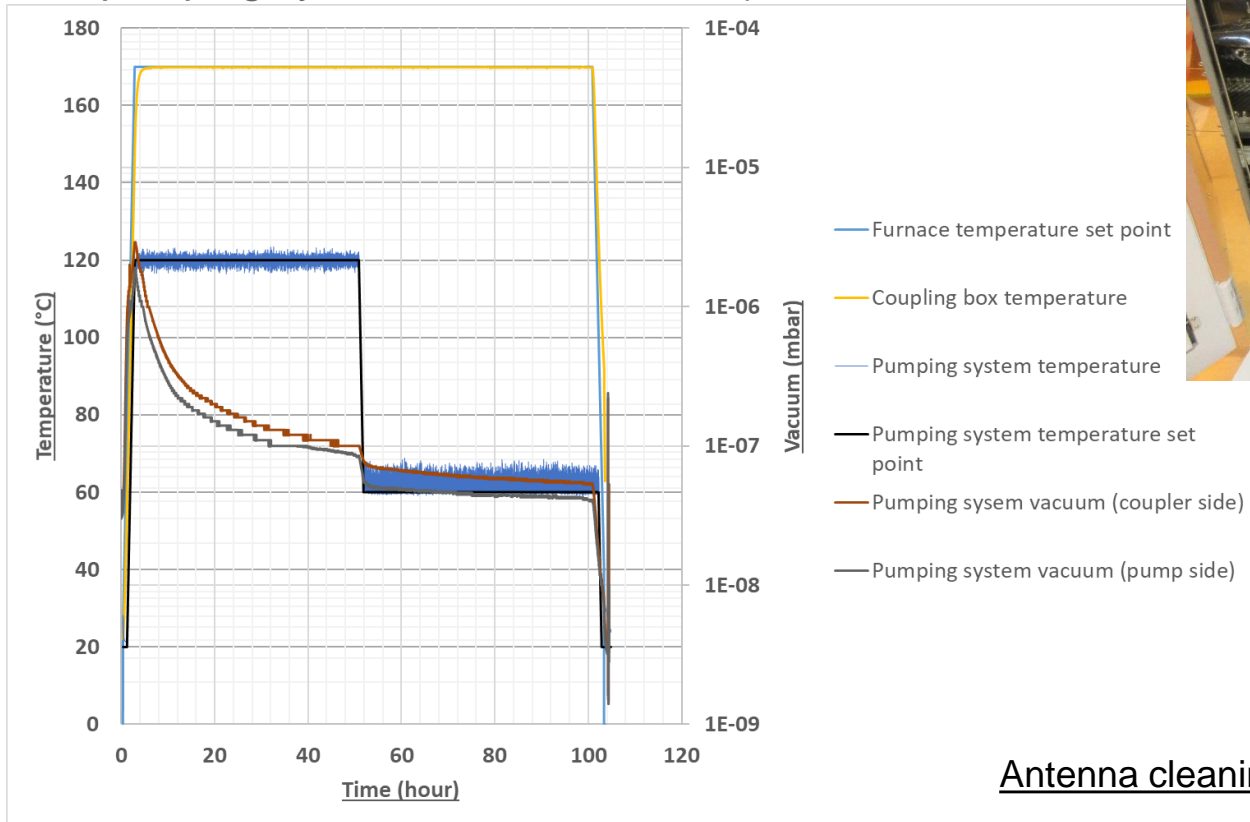


Photomultiplier (air side)

- Cleaning of the components:
  - Ultrasonic bath for double-wall tubes (Tickopur R33 detergent)
  - Manual cleaning for window (absolute ethanol, antenna cleaned with RBS T310)
- Assembly in a ISO5 cleanroom
- Baking in an oven (couplers 170°C for 4-5 days, pumping system 120°C then 60°C)



Couplers in the oven



Baking (temperature and vacuum)

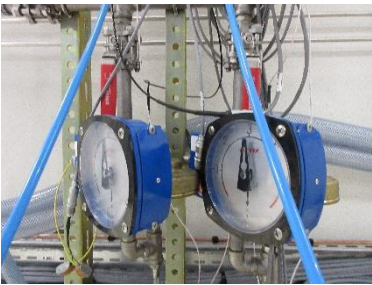
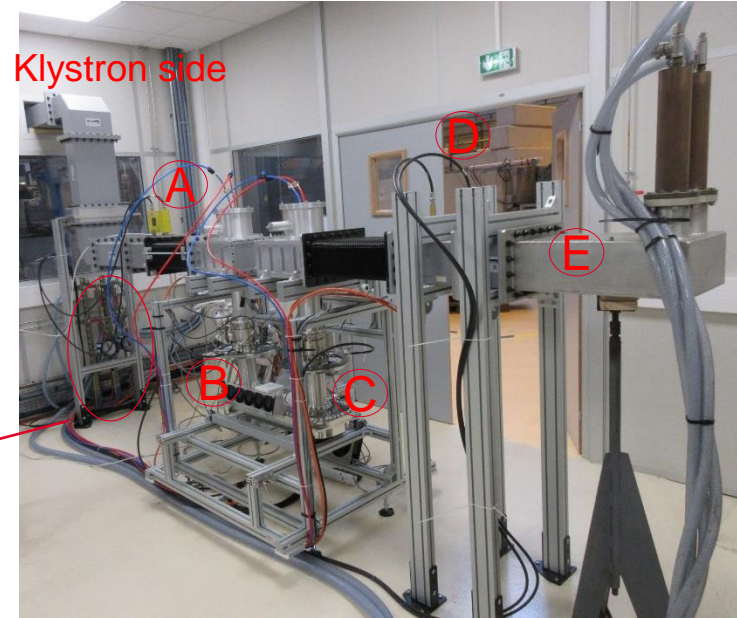


Antenna cleaning



Double-wall cleaning

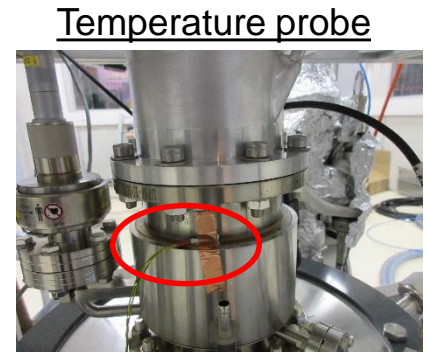
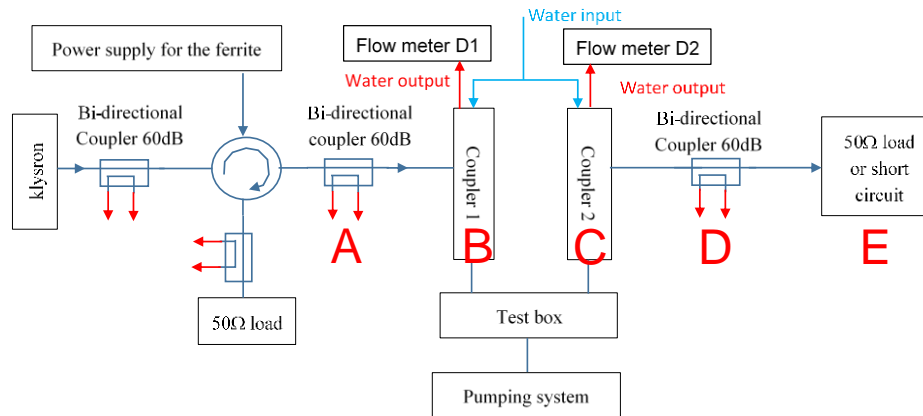
- **Vacuum**: couplers and pumping system
- **RF power (incident & reverse)**: output of the klystron, input of the couplers, output of the couplers, image of the power in the coupler with the electron pick-up
- **Electrical arcs**: 2 photomultipliers for each ceramic, 1 for the test box
- **Multipactor** :electron pick-up
- **Water**: flowmeter and temperature probes (input, output)
- **Couplers temperature**: probes put on the window and on the box



Water flowmeter

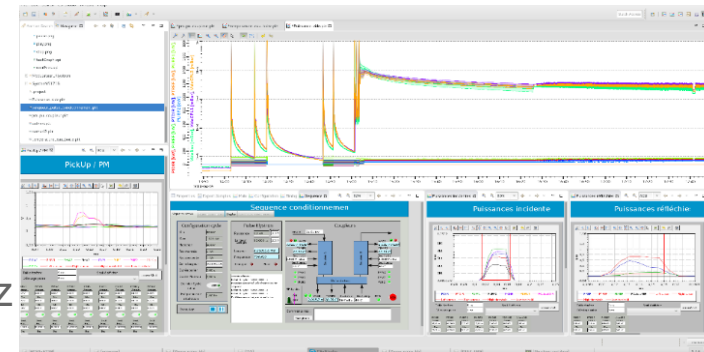


Photomultiplier on the coupling box



Temperature probe

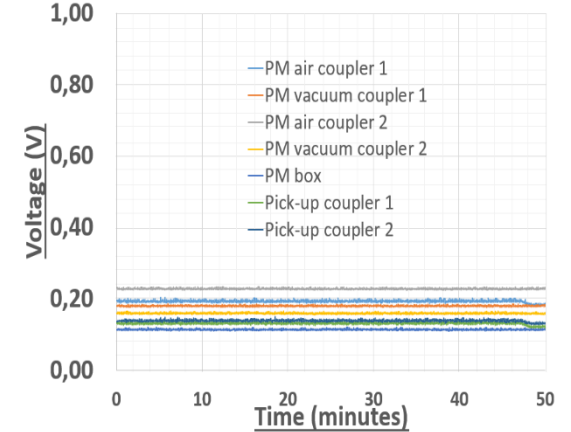
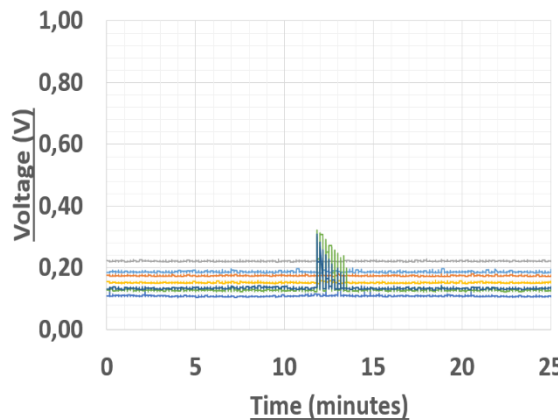
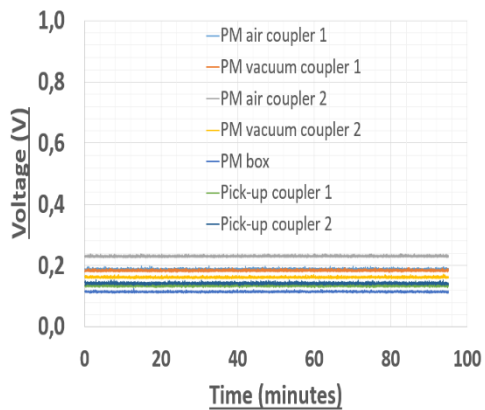
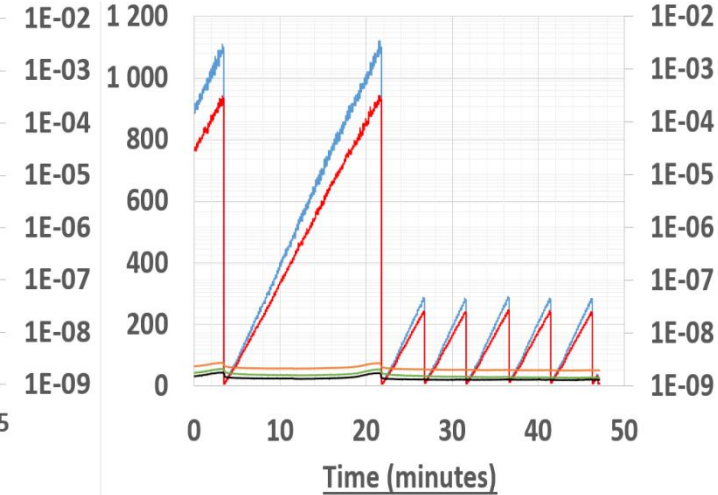
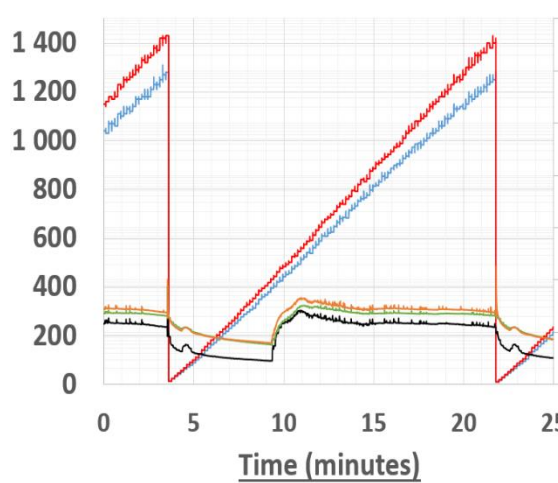
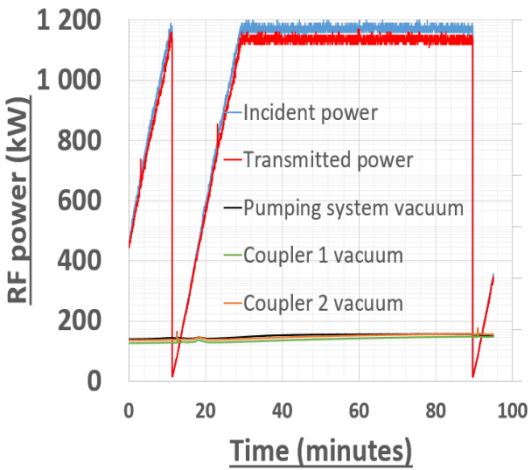
- RF power ramps from around 10 kW to 1.1 MW (pulse width from 50 $\mu$ s to 3.6ms), increase step by step (usually 1 kW per second). Increase or decrease of the power according to outgassing
- RF power switched off when
  - Outgassing with a vacuum level exceeding a hardware threshold defined at 1x10<sup>-6</sup> mbar
  - Presence of electrical arcs whose intensity is greater than around 3 lux (photomultiplier),
  - Presence of electrons whose intensity is greater than 8 mA (detected with the electron pick-up).
- Conditioning sequence:
  - Conditioning in travelling wave at 1 Hz
  - Conditioning in travelling wave at 14 Hz
  - Conditioning in standing wave at 1 Hz
  - Conditioning in standing wave at 2 Hz, 4 Hz, 8Hz
  - Conditioning in standing wave at 14 Hz.
- The automated handling of all the conditioning sequences, the interlocks and the data recording are controlled with EPICS



TW, 14Hz, 3.6ms

SW, 14Hz, 500µs, Min E

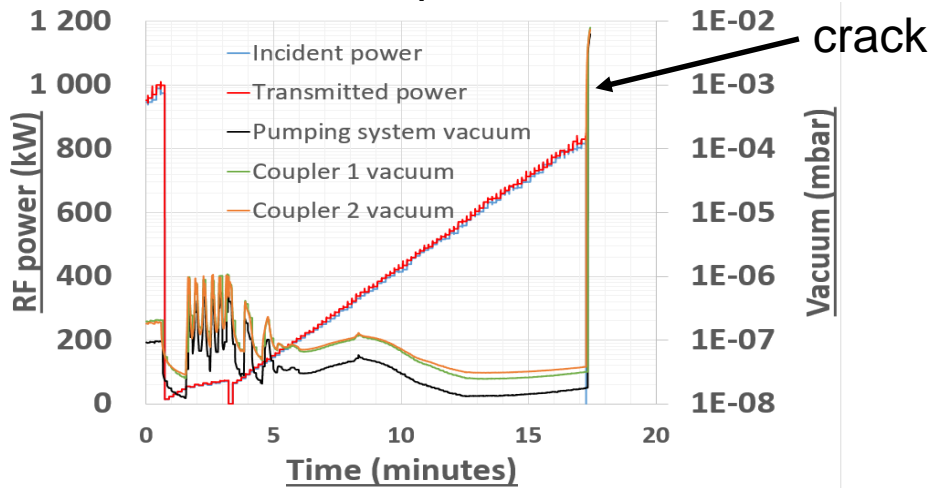
SW, 14Hz, 500µs-3.6ms, Max E



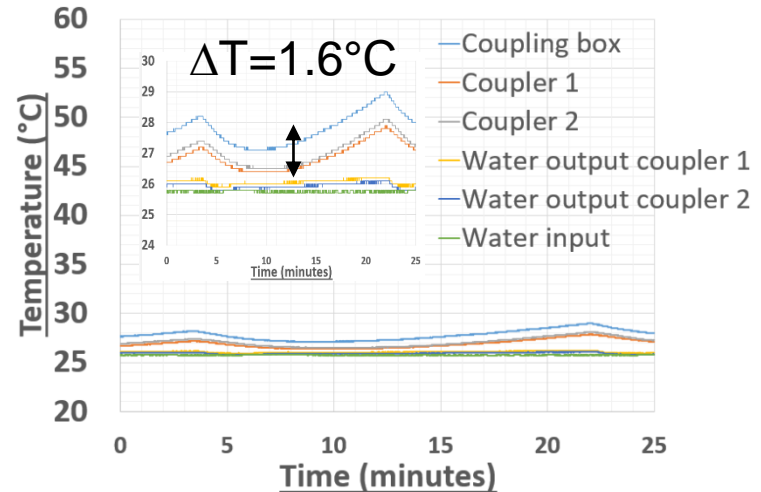
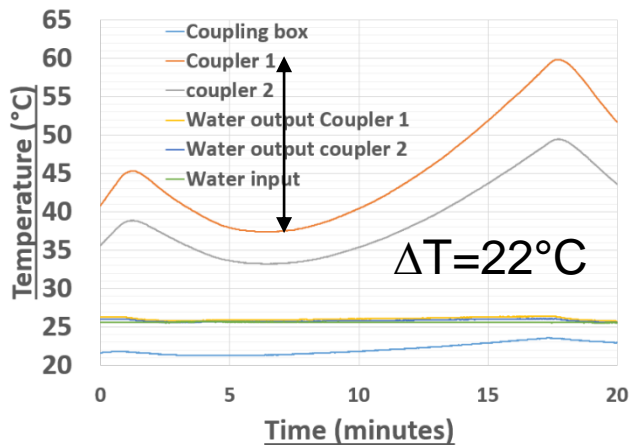
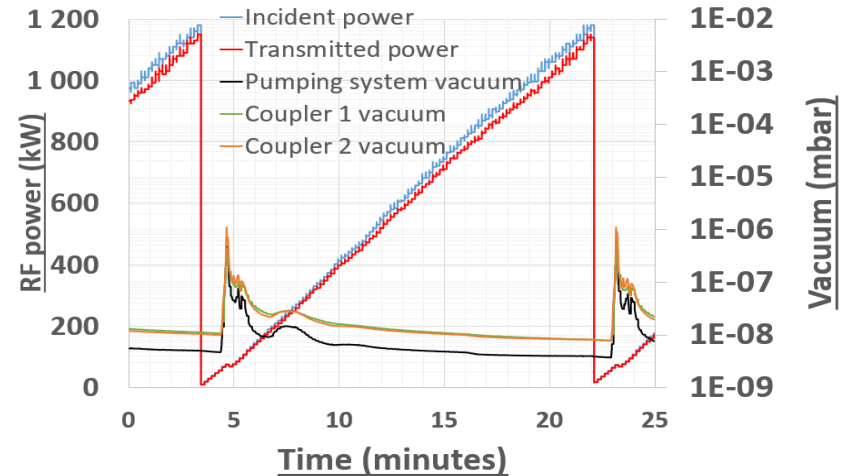
⇒ Successful conditioning with minimum outgassing and electron activity

- During the conditioning of the first series couplers pair, **a crack** occurred on the ceramic (travelling wave, 14Hz, 2.5ms at 800kW) ⇒ loss of vacuum tightness
- Inspection of the other diagnostic signals ⇒ window temperature increased highly

## Series coupler

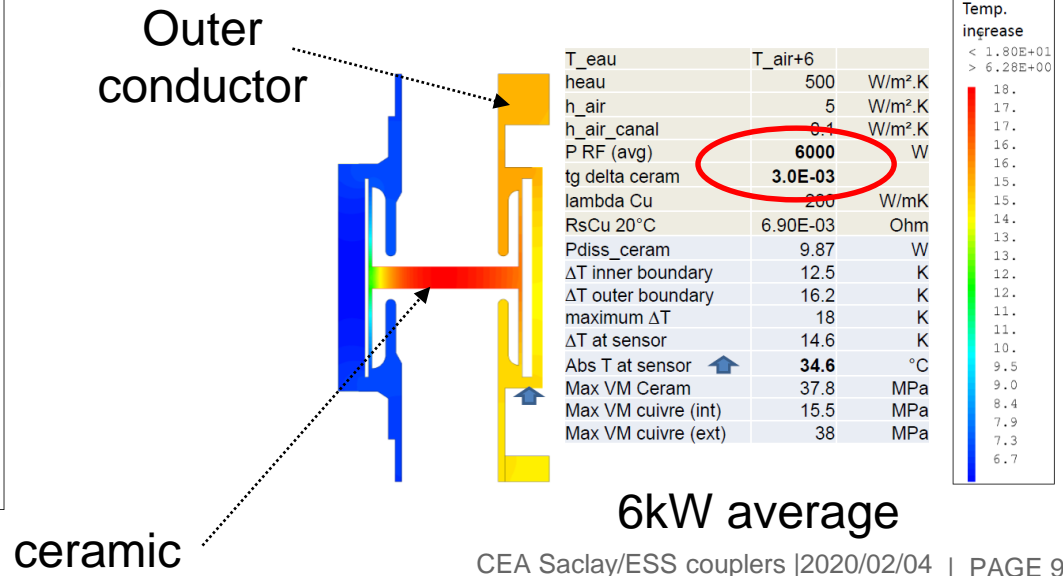
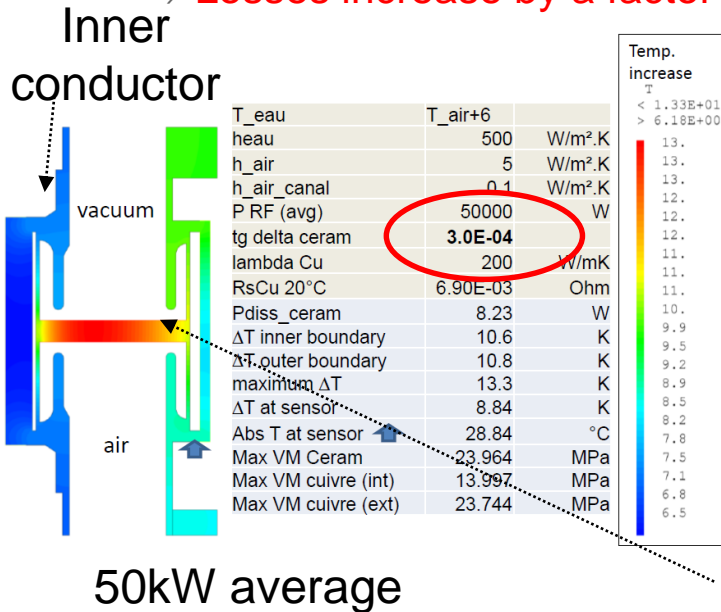


## Pre-series coupler



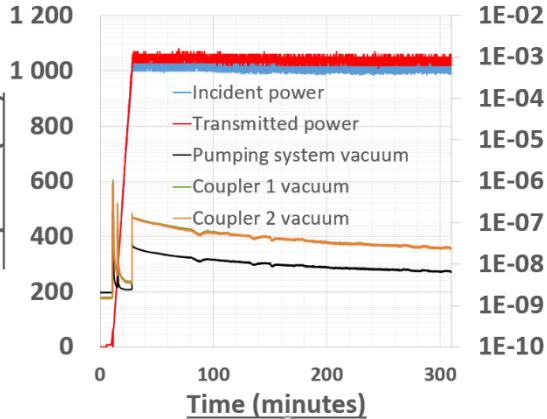


- We performed the conditioning with another pair, same temperature behavior as for the coupler with crack. Stop of the conditioning.
- Simulation performed to explain the temperature behavior of the couplers
  - With the nominal dielectric properties of the ceramic (nominal average power 55kW-3.6ms, 14Hz, 1MW peak), impossible to find the high temperature in spite of pessimistic heat transfer coefficients
  - Increase of dielectric losses (x10), average power 6kW obtained when we stop the conditioning ⇒ simulation similar to the temperature measurement
- Characterization of a ceramic without TiN ( $\epsilon_r=9.47$  and  $\tan \delta= 2.78 \cdot 10^{-4}$ ) and a ceramic with bad TiN ( $\epsilon_r=9.44$  and  $\tan \delta= 2.04 \cdot 10^{-3}$ ) with measurements at 1.8GHz in a resonant cavity  
 ⇒ **Losses increase by a factor 10 with the TiN coating**

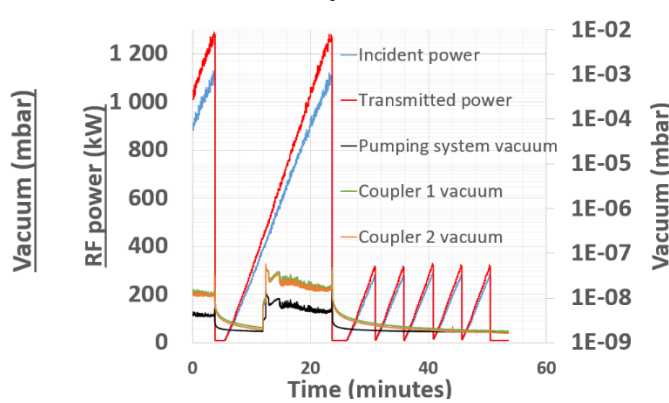


To be sure that this temperature behavior comes (only) from a bad TiN coating, we conditioned a coupler without TiN coating (associated with a prototype coupler with a good TiN coating).

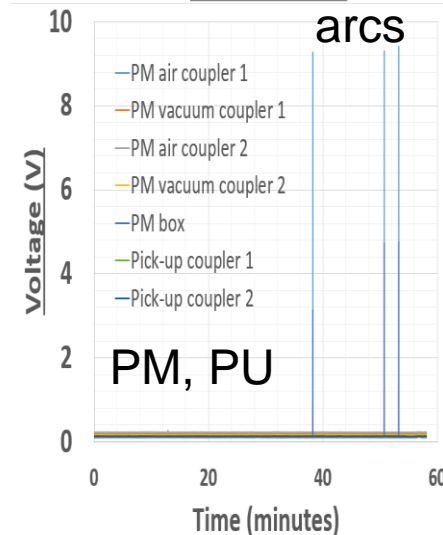
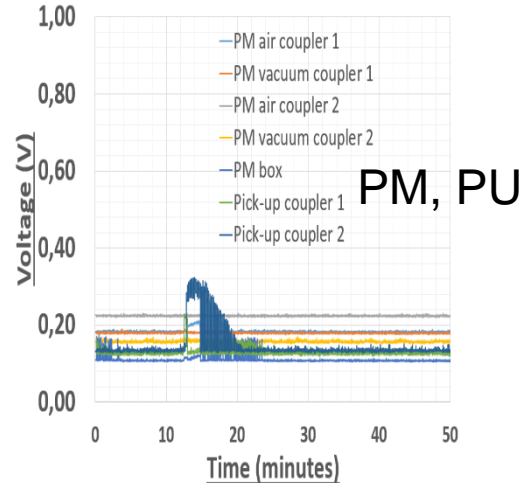
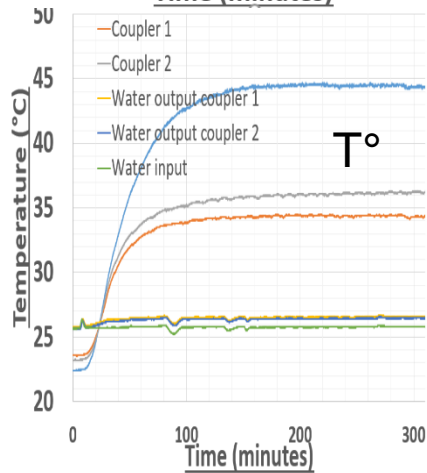
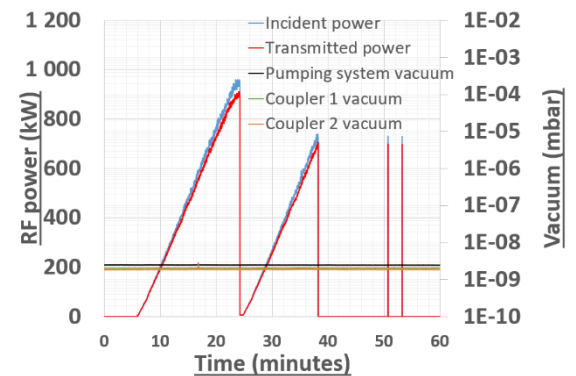
TW, 14Hz, 3.6ms



SW, 14Hz, 500µs-3.6ms, Min E

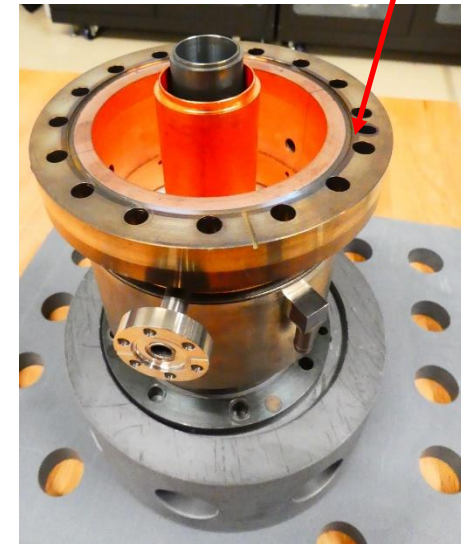


SW, 1Hz, 50µs, Max E



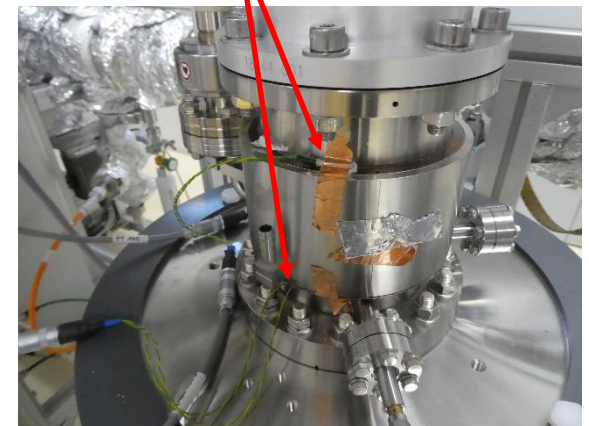
⇒ Normal temperature behavior but conditioning stopped in SW (Max E) due to lots of electrical arcs

- In the manufacturing process, the TiN coating is performed after brazing of the ceramic
- Currently, the TiN subcontractor doesn't succeed in performing the same TiN coating as for the pre-series. Work with another TiN subcontractor
- Tests performed before TiN coating of the window:
  - TiN coating on samples (silicon or vitreous carbon) put on a ceramic in a mock-up similar to the window
  - Thickness and stoichiometric measurements on the samples
  - TiN coating on a ceramic in the mock-up
  - Low level RF measurement on the ceramic in the mock-up (reflection and transmission coefficients)
  - Measurement of the resistance of the TiN coating with a multimeter
- Tests after TiN coating of the window (before welding of the antenna):
  - Low level RF measurement of the window
  - Measurement of the resistance of the TiN coating with a multimeter
  - Thickness measurement on samples put on the flange



- For the mass production couplers, change of TiN subcontractor.
- The preliminary tests on samples and on coated windows seem to be correct
- **The next windows with the new TiN coating will be conditioned at CEA in February-March**
  
- In terms of conditioning:
  - The RF power ramp is managed with the vacuum on the coupler
  - We add a criterion on the window temperature in order to switch off the RF power when the temperature is too high
  - We add supplementary temperature probes around the ceramic
  - RF power is switched off with specific phenomena on :
    - Vacuum
    - Electrical arcs
    - Multipactor
    - Coupler temperature
    - Water flow
    - Electric arcs on the air side(for these 3 last phenomena, the operator has to reset the defaults)  
⇒ **Lots of criteria to follow the conditioning**

Temperature probes



THANK YOU FOR  
YOUR ATTENTION

Commissariat à l'énergie atomique et aux énergies alternatives  
Centre de Saclay | 91191 Gif-sur-Yvette Cedex  
T. +33 (0)1 69 08 xx xx | F. +33 (0)1 69 08 99 89

DSM  
Irfu

Etablissement public à caractère industriel et commercial | RCS Paris B 775 685 019